

**Erratum: Correlation between self-diffusion in Si and the migration mechanisms of vacancies and self-interstitials: An atomistic study [Phys. Rev. B **78**, 035208 (2008)]**

M. Posselt, F. Gao, and H. Bracht  
(Received 12 February 2009; published 5 March 2009)

DOI: [10.1103/PhysRevB.79.119901](https://doi.org/10.1103/PhysRevB.79.119901)

PACS number(s): 61.72.Bb, 85.40.Ry, 61.80.Az, 99.10.Cd

In the caption of Fig. 9 on p. 035208-8 is a typographical error. The term  $\langle 110 \rangle$  dumbbell which occurs twice in the figure caption should be replaced by the term  $\langle 100 \rangle$  dumbbell. The figure is discussed correctly in the text.